

マイクロリアクターは化学プロセスに どう役立つか(過酸化水素製造を中心に)



2002



2008



2013

2014年7月4日
UMEMSME-AIST
井上 朋也



本日の話題



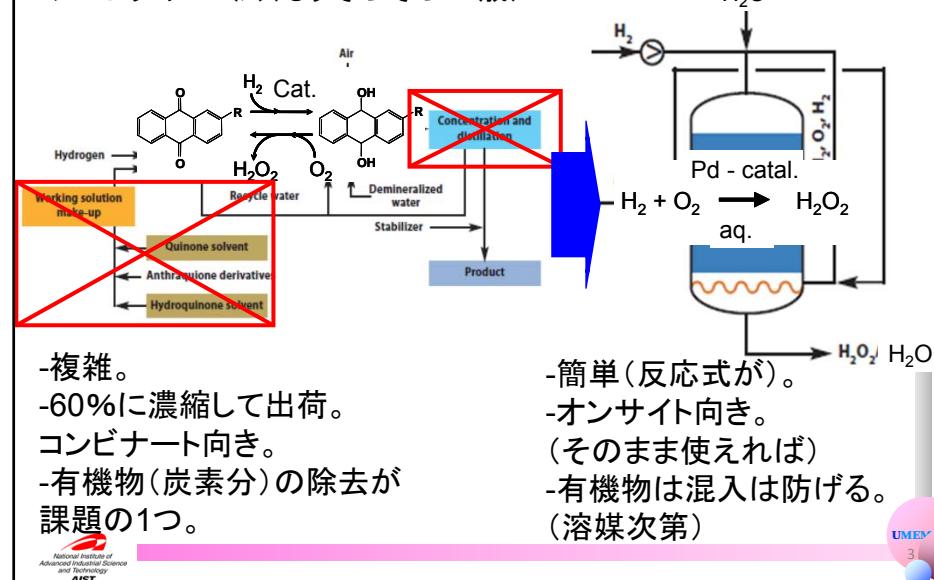
1. 背景～過酸化水素X直接製造Xマイクロリアクター
2. マイクロリアクター～デザインX触媒反応解析
3. まとめ、と、やりのこし



1. H_2O_2 – its process

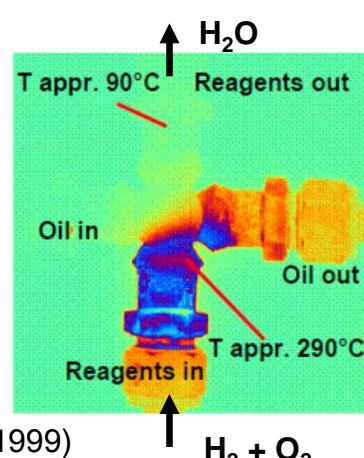
アントラキノン法(もうそろそろ70歳)

直接法
(まだ産まれてません)



Microreactor for... H_2 - O_2 reaction

-幅300 μm マイクロチャンネルによる爆発反応の完全制御
(Max Planck + FZK, 1998)

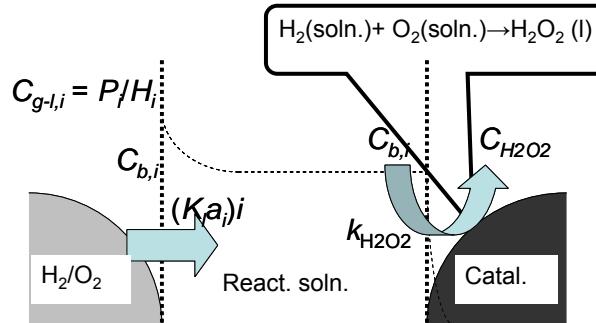


(Max Planck Inst. Annual Report, 1999)

-触媒をコートしたマイクロチャンネル。



ちょっと複雑な直接製造法



- 実際には水素も酸素もいったん水に溶けて、**溶存水素および酸素が触媒上で反応する**(どちらも**溶けづらい**が)。

- 気液固の共存は**必須**。

- 物質移動効率は、高いほどよい。

…どういう反応器がよいのか？

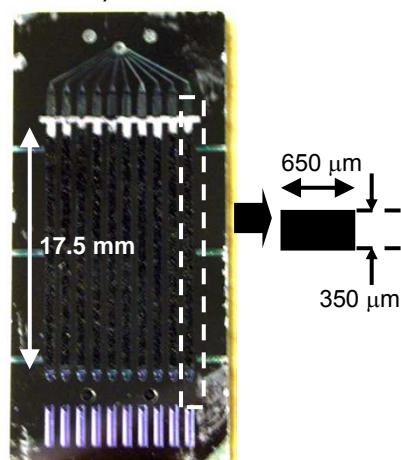
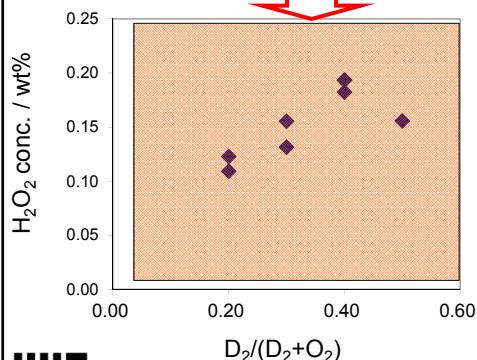


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2. Microreactor - for the Direct H_2O_2

*Rapid heat removal (+ radical termination) at a channel wall = Perfectly controlled H_2 - O_2 reaction

All conditions are in
explosive region.



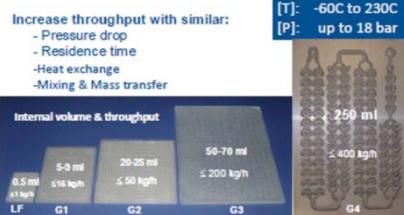
Inoue, T., et al., IMRET7, (2003).
Inoue, T., et al., IECR 2007, **46**, 1153.

IMRET 7 – September 9, 2003

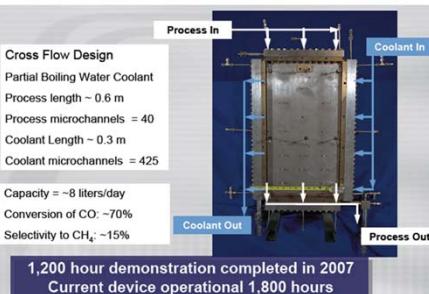


誰がつくってくれませんか

Different Glass Fluidic Module:
from lab to production



Pilot Scale Demonstration Unit



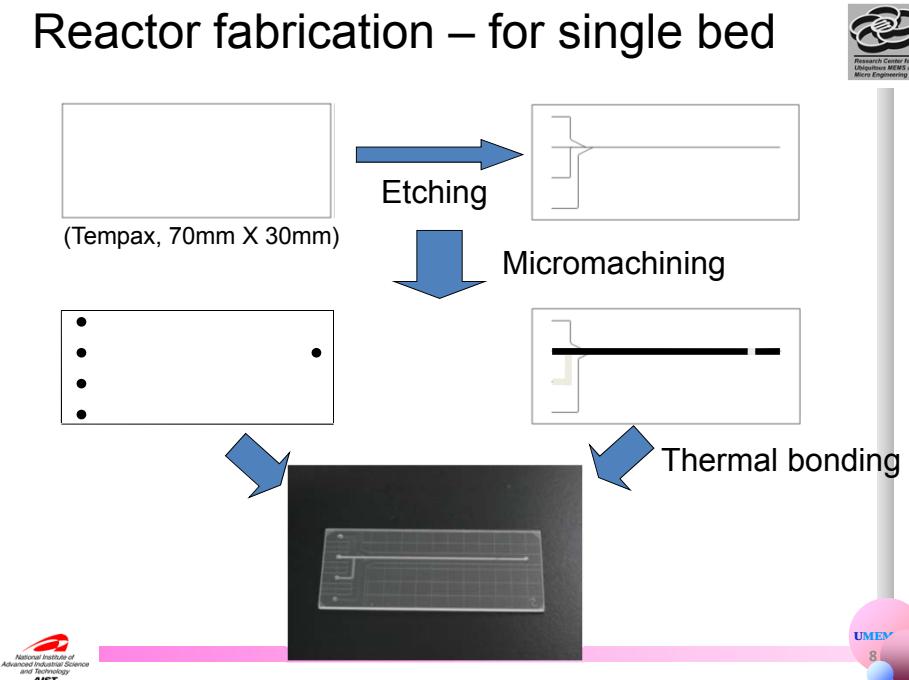
Corning: ものを詰めるのは不可。

Velocys: 気相反応。いきなり購入するのも…

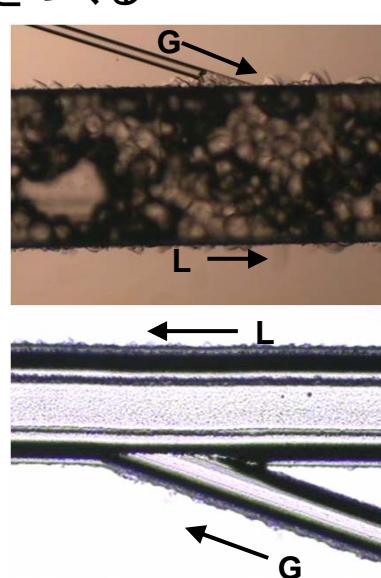
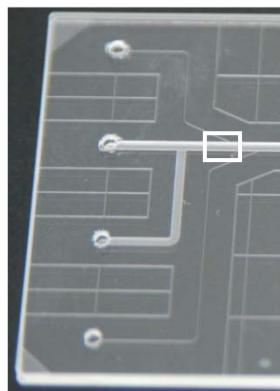
…やはり自分でつくります。



Reactor fabrication – for single bed



安定な“気液混相流”をつくる



$$*\Delta P \propto \mu, V_s$$

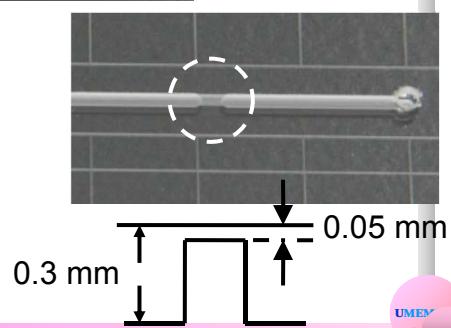
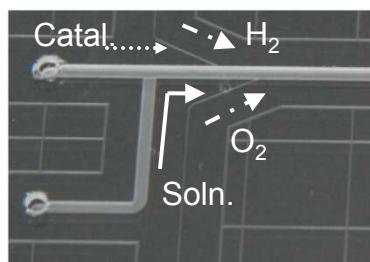
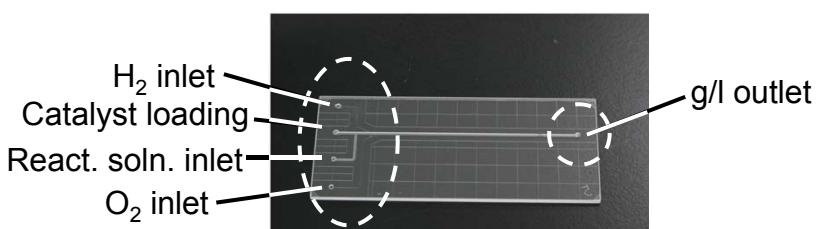
$$(\mu_g \sim 10^{-3} \text{cP}, \mu_l \sim 1 \text{cP})$$

Chem. Eng. J., 160, 909 (2010).



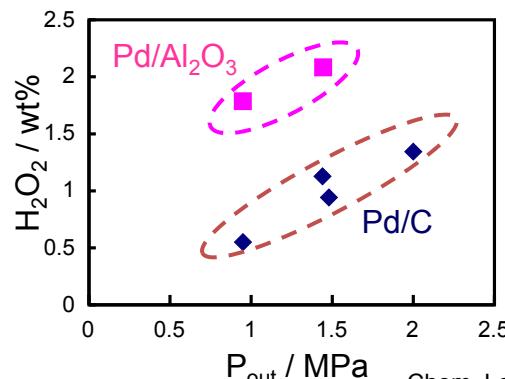
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正しいシングルレベル



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気液が正しく流れれば…



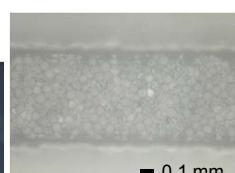
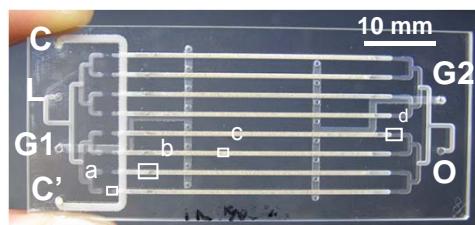
Chem. Lett. 38, 820 (2009).
Chem. Eng. J. 160, 909 (2010).

…マイクロリアクターは、“理想的な”
反応場である。

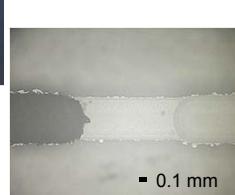


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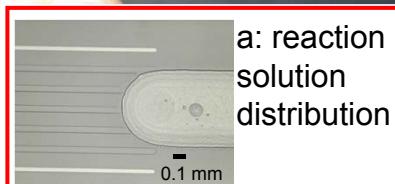
Reactor design



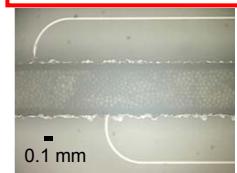
c: packed bed



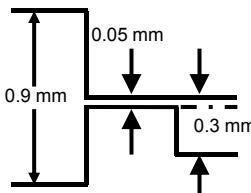
d: dam structure



a: reaction
solution
distribution



b: gas-liquid
mixture

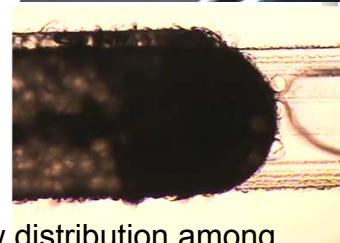
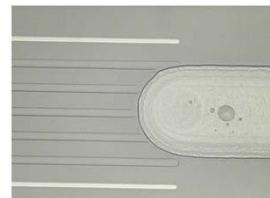
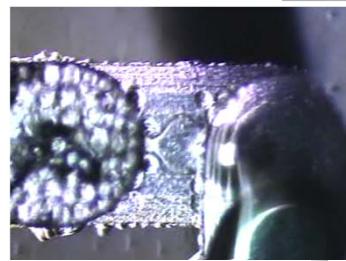
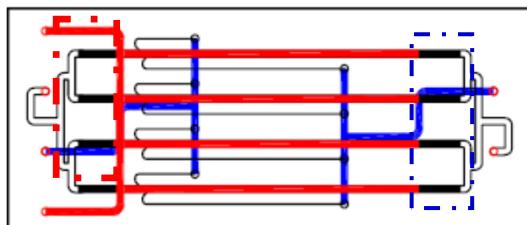


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Go #‐up successful

$V_L=0.04 \text{ ml/min (}0.01 \times 4\text{)}$
 $V_G=2.0 \text{ sccm (}0.5 \times 4\text{)}$



- Liquid distributor validates equal flow distribution among channels.

Proc. mTAS. 2010, 1694.
JJAP. 51, 06FK11 (2012).



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How 32ch reactor looks like?

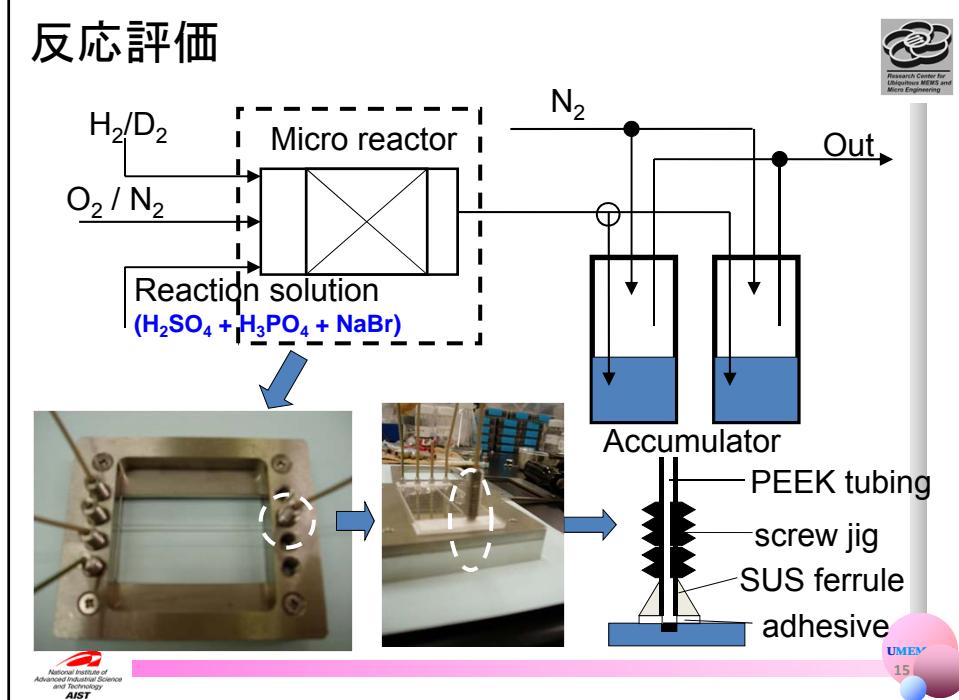


(to be in ナノテク展2014)



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反応評価



Reactor performances

Reactor (Pd1-Au0.7/TiO ₂ , Au/Pd=0.7) 1MPa, ca. 296 K	$H_2/(H_2+O_2)$ (Liq. rate [mLmin ⁻¹], gas rate [sccm])	H_2O_2				T_{surf} [K]
		C_{H_2} [%]	S_{HO} [%]	W_{HO} [wt%]	Rate (cat. wt) [10 ⁻⁴ molh ⁻¹ (g)]	
	0.2 (0.01, 5.0)	15	86	2.9	3.6 (0.017)	295
	0.2 (0.08, 40)	30	90	2.8	39.2 (0.121)	297
	0.2 (0.16, 80)	49	68	4.4	123 (0.271)	313
	0.1 (0.16, 80)	24	79	1.5	41.4	296

…ちゃんと“ナンバリングアップ”できました。UMEM 16

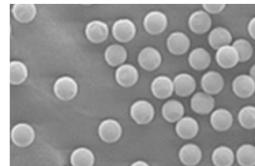
触媒・・・



-Pd/ Al_2O_3 was purchased from N. E. Chemcat Co. (5 wt%).

-Pd/ TiO_2 and Pd-Au/ TiO_2 were prepared by (co-) Impregnation, using chloride as metal resources.

-Support morphology: spherical, 0.06 mm diameter, monodispersed.



コバレントマテリアル株式会社

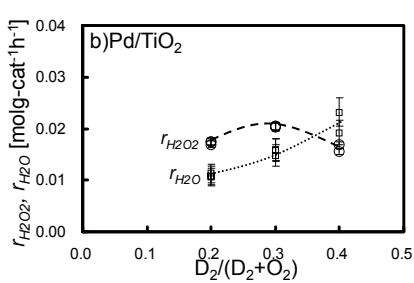
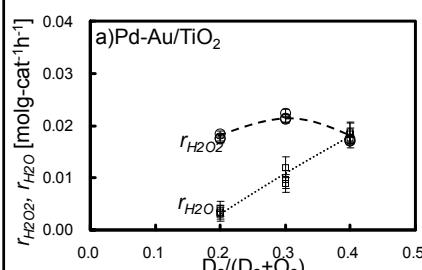
	Productivity	ΔP	Stability	S. A.
TiO_2	◎ (10%)	◎(<0.1 MPa)	○	△($16\text{m}^2\text{g}^{-1}$)
C	△ (1-2%)	✗ (>0.4MPa)	✗ (burn off)	◎ ($200\text{m}^2\text{g}^{-1}$)
Al_2O_3	○ (6%)	◎(<0.1 MPa)	○	○

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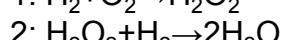
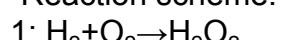
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What is different?

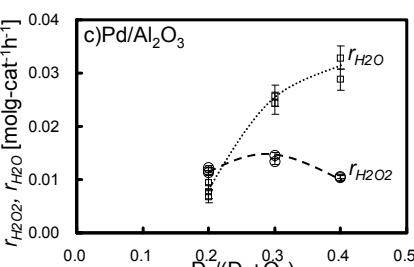


-Reaction scheme:



- TiO_2 supported catalyst suppresses 2, also with Au modification.

Fuel Proc. **108**, 8 (2013).



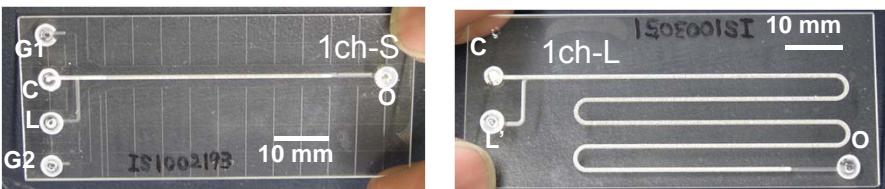
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Reactor performances @ 1 MPa, RT.



Catalyst / reactor	Inlet condition $D_2/(D_2+O_2)$ (f_L, f_G)	D ₂ conversion / D ₂ O ₂ (H ₂ O ₂) production			
		C [%]	S [%]	W [wt%]	rate ^[b]
Pd/Al_2O_3 (N. E., 5 wt%)					
8ch-S	0.1 (0.01, 40)	48	20	6.3	10.2 (0.7)
Pd/TiO_2					
1ch-S+1ch-L	0.3 (0.01, 5.0)	81	46	10.4	14.9 (1.2)
$Pd-Au/TiO_2$ (Pd1-Au0.5)					
8ch-S	0.175 (0.01, 40)	22	50	11.7	20.5 (1.5)
1ch-S+1ch-L	0.3 (0.01, 5.0)	80	45	9.9	14.4 (1.2)



Inoue, T., et al., Fuel Proc. Tech., 2013, 108, 8. 19

3. まとめ…

Conventional

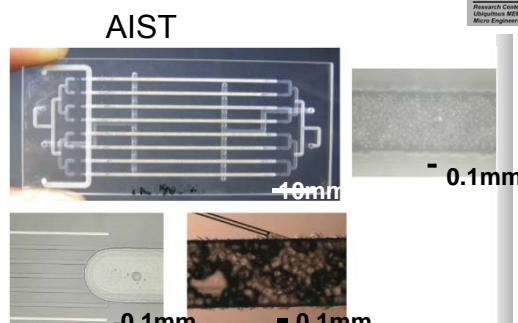


(超低温反応設備、和光純薬)

-Batch / CSTR

-5.0~9.5 MPa

-H₂: 3.6 vol. %



-Reaction conditions become moderate, by *intensified heat/mass transfer*.



-PFR / Fixed-bed

-1.0 MPa↓

-H₂: 10 vol. %↑

